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PATENT APPLICATION



THE UNITED STATES PATENT AND TRADEMARK OFFICE

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Docket No: Q78162

Yoshiyuki FUKUMOTO, et al.

Appln. No.: 10/697,124

Group Art Unit: 2836

Confirmation No.: 8462

Examiner: Not Yet Assigned

Filed: October 31, 2003

For:

MAGNETORESISTANCE DEVICE AND METHOD OF FABRICATING THE SAME

INFORMATION DISCLOSURE STATEMENT UNDER 37 C.F.R. §§ 1.97 and 1.98

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In accordance with the duty of disclosure under 37 C.F.R. § 1.56, Applicant hereby notifies the U.S. Patent and Trademark Office of the documents which are listed on the attached PTO/SB/08 A & B (modified) form and listed herein and which the Examiner may deem material to patentability of the claims of the above-identified application.

- 1. <u>Serial No.</u> <u>Applicant's Name</u> <u>Filing Date</u>
 - 10/539,373 Yoshiyuki FUKUMOTO, et al. June 16, 2005
- 2. Japanese Patent Application Publication No. 62-132211, published June 15, 1987.
- 3. Japanese Patent Application Publication No. 3-268216, published November 28, 1991.
- 4. European Patent Application Publication No. 1 202 357, published May 2, 2005.
- 5. Japanese Patent Application Publication No. 2002-329903, published November 15, 2002.

INFORMATION DISCLOSURE STATEMENT

U.S. Appln. No.: 10/697,124 Atty. Docket No.: Q78162

6. Japanese Patent Application Publication No. 2003-273420, published September 26, 2003.

- 7. J. J. Sun, et al.; "Low resistance and high thermal stability of spin-dependent tunnel junctions with synthetic antiferromagnetic CoFe/Ru/CoFe pinned layers"; Applied Physics Letters; April 24, 2000; Vol. 76, No. 17; pages 2424-2426.
- 8. S. Cardoso, et al.; "Influence of Ta antidiffusion barriers on the thermal stability of tunnel junctions"; Applied Physics Letters; June 19, 2000; Vol. 76, No. 25; pages 3792-3794.
- 9. T. Ochiai, et al.; "Improved Thermal Stability of Ferromagnetic Tunnel Junctions With a CoFe/CoFeO_x/CoFe Pinned Layer"; IEEE Transactions on Magnetics; September 2003; Vol. 39, No. 5; pages 2797-2799.

One copy of each of the listed documents is submitted herewith, except for the copending non-provisional U.S. application filed after June 30, 2003.

The present Information Disclosure Statement is being filed: (1) No later than three months from the application's filing date; (2) Before the mailing date of the first Office Action on the merits (whichever is later); or (3) Before the mailing date of the first Office Action after filing a request for continued examination (RCE) under §1.114, and therefore, no Statement under 37 C.F.R. § 1.97(e) or fee under 37 C.F.R. § 1.17(p) is required.

In compliance with the concise explanation requirement under 37 C.F.R. § 1.98(a)(3) for foreign language documents, Applicant states that above references 2 and 3 are discussed within the specification of co-pending U.S. Application No. 10/539,373, beginning at page 10, line 27, and page 11, line 8, respectively. Regarding above references 5 and 6, Applicant encloses herewith a copy of an International Search Report issued in the International Application corresponding to co-pending U.S. Application No. 10/539,373, which cites these documents and indicates the degree of relevance found by the foreign patent office.

INFORMATION DISCLOSURE STATEMENT

U.S. Appln. No.: 10/697,124

Atty. Docket No.: Q78162

The submission of the listed documents is not intended as an admission that any such

document constitutes prior art against the claims of the present application. Applicant does not

waive any right to take any action that would be appropriate to antedate or otherwise remove any

listed document as a competent reference against the claims of the present application.

The USPTO is directed and authorized to charge all required fees, except for the Issue

Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any

overpayments to said Deposit Account. A duplicate copy of this paper is attached.

Respectfully submitted,

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WASHINGTON OFFICE

23373

CUSTOMER NUMBER

Date: December 7, 2005

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Substitute for Form 1449-A & B/PTO		Complete if Known		
		Application Number	10/697,124	
INFO	ORMATION D	ISCLOSURE 43	Confirmation Number	8462
			Filing Date	October 31, 2003
7 700 8			First Named Inventor	Yoshiyuki FUKUMOTO
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			Examiner Name	Not Yet Assigned
Sheet	1	of 1 CATEA	Attorney Docket Number	Q78162

			U.S.	PATENT DOCUME	ENTS	
Examiner Cit Initials* No.	Cita	Document :	Document Number			
	No.1	Number	Kind Code ² (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	
		US				
		US				
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			FC	DREIGN PA	TENT DOCUM	ENTS	
Examiner Cite Initials* No.¹	Foreign Patent Document			Publication Date	Name of Patentee or	m 1 11 6	
	Country Code ³	Number ⁴	Kind Code ⁵ (if known)	MM-DD-YYYY	Applicant of Cited Document	Translation ⁶	
		JP	62-132211	A	06-15-1987		
		JP	3-268216	A	11-28-1991		
		EP	1 202 357	A2	05-02-2002	Matsushita Electric Industrial Co., Ltd.	
		JР	2002-329903	A	11-15-2002		
		JР	2003-273420	Α	09-26-2003		
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		NON PATENT LITERATURE DOCUMENTS		
Examiner Cite Initials* No.1		Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city, and/or country where published.		
		U.S. Appln. No. 10/539,373, filed by Yoshiyuki FUKUMOTO, et al. on June 16, 2005.		
		J. J. Sun, et al.; "Low resistance and high thermal stability of spin-dependent tunnel junctions		
		with synthetic antiferromagnetic CoFe/Ru/CoFe pinned layers"; Applied Physics Letters; April		
		24, 2000; Vol. 76, No. 17; pages 2424-2426.		
		S. Cardoso, et al.; "Influence of Ta antidiffusion barriers on the thermal stability of tunnel junctions"; Applied Physics Letters; June 19, 2000; Vol. 76, No. 25; pages 3792-3794.		
		T. Ochiai, et al.; "Improved Thermal Stability of Ferromagnetic Tunnel Junctions With a CoFe/CoFeOx/CoFe Pinned Layer"; IEEE Transactions on Magnetics; September 2003; Vol. 39, No. 5; pages 2797-2799.		

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Examiner Signature		Date Considered	ı	

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹Applicant's unique citation designation number (optional). ²See Kind Codes of USPTO Patent Documents at www.uspto.gov, MPEP 901.04 or in the comment box of this document. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST. 3). ⁴For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. ⁶ Applicant is to indicate here if English language Translation is attached.